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IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF:

HEIKO MAAS ET AL.

SERIAL NO: NEW US PCT APPLN.

(Based on PCT/EP00/02902)

: ATTN: APPLICATION BRANCH

FILED: HEREWITH

FOR: METHOD FOR PRODUCING

ALKAPOLYENYL COMPOUNDS USING CERTAIN COCATALYSTS

PRELIMINARY AMENDMENT

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

SIR:

Prior to examination on the merits, please amend the above-identified application as follows:

IN THE SPECIFICATION

Please delete the title on Page 1, lines 1-2 and replace with the following title.

METHOD FOR PRODUCING ALKAPOLYENYL COMPOUNDS USING CERTAIN

COCATALYSTS.

13 IN THE CLAIMS

Please cancel Claims 4-13.

Please add new Claims 14-25.

2. Keys 8/24/04 Os says of

(New) A process as claimed in claim 1, wherein hydrogen chloride is used in form of hydrochloric acid.

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(New) A process as claimed in claim 1, wherein the amount of cocatalyst is from 5 to 10³ mol per gram atom of rhodium.

PHD4

16. (New) A process as claimed in claim 1, wherein, in addition, hydrogen is added to the reaction medium.

17. (New) A process as claimed in claim 1, wherein, in addition, at least one organic halide is dissolved in the reaction medium.

18. (New) A process as claimed in claim 1, wherein R^1 is C_1 - C_6 -alkyl or phenyl.

19. (New) A process as claimed in claim 18, wherein R¹ is methyl.

20. (New) A process as claimed in claim 1, wherein R², R³, R⁴, R⁵, R⁶, R⁷ and R⁸ are

hydrogen.

21. (New) A process as claimed in claim 1, wherein R^1 is C_1 - C_6 -alkyl or phenyl, and R^2 , R^3 , R^4 , R^5 , R^6 , R^7 and R^8 are hydrogen.

22. (New) A process as claimed in claim 21, wherein R¹ is methyl.

23. (New) A process as claimed in claim 1, wherein the rhodium compound is selected from rhodium(III) salts, in particular rhodium trichloride, and π -allyl complexes of rhodium, in particular bis(π -crotyl)tetrachloro(butadiene)dirhodium.

out in the presence of rhodium compounds, of 1-substituted alka-2,7-dienes of the formula I and/or 3-substituted alka-1,7-dienes of the formula II,

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$$R^{1}O$$
 R^{2}
 R^{4}
 R^{5}
 R^{5}
 $R^{1}O$

where R¹ is hydrogen or C₁-C₆-alkyl, C₅-C₈-cycloalkyl, C₁-C₆-alkanoyl, C₆-C₁₂-aryloyl or C₇-C₁₈-aralkyl each of which may be unsubstituted or monosubstituted, disubstituted or trisubstituted by hydroxy, C₁-C₆-alkoxy, C₁-C₆-alkanoyloxy and/or halogen, and R², R³, R⁴ and R5 are, independently of one another, hydrogen or C1-C6-alkyl, with 1,3-conjugated dienes of the formula III

$$\mathbb{R}^6$$
 \mathbb{R}^8
(III)

where R^6 and R^7 are, independently of one another, hydrogen or $C_1\text{-}C_6\text{-alkyl}$, and R^8 is hydrogen, C₁-C₆-alkyl or C₂-C₆-alkenyl,

which method comprises dissolving hydrogen chloride, GeCl₄ and/or WCl₆ in the reaction mixture.

24 25 (New) A method for preparing a surface-active material, which method comprises providing alkapolyenyl compounds obtained by a process as claimed in claim 1